
Electrochemical Engineering for the 21st Century 2

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Table of Contents

<i>Preface</i>	<i>iii</i>
Cellular Automation for the Self-Organization Processes at the Annealing of Silicon Rich Oxide Layer <i>O. M. Orlov, I. V. Matyushkin, S. V. Korobov, G. Y. Krasnikov</i>	1
Author Index	11